

CHAPTER SIXTEEN

Metal Oxide Semiconductor Field Effect Transistors [MOSFET]

Digital Electronics.

Introduction

MOSFET transistors have smaller size than BJT transistors

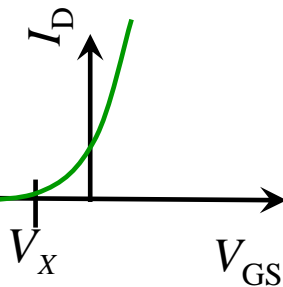
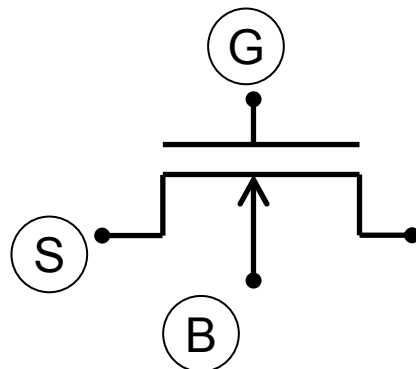
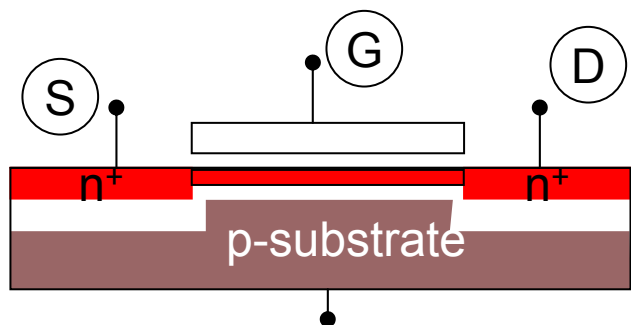
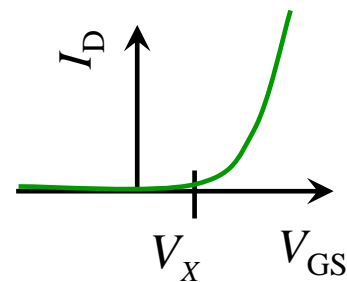
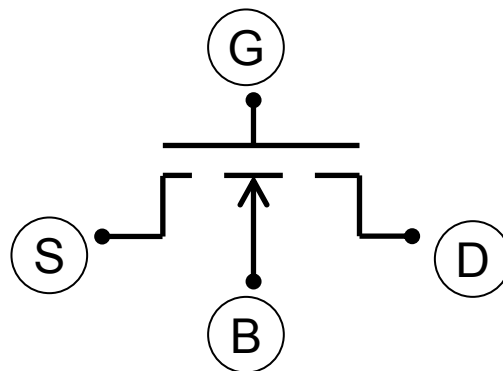
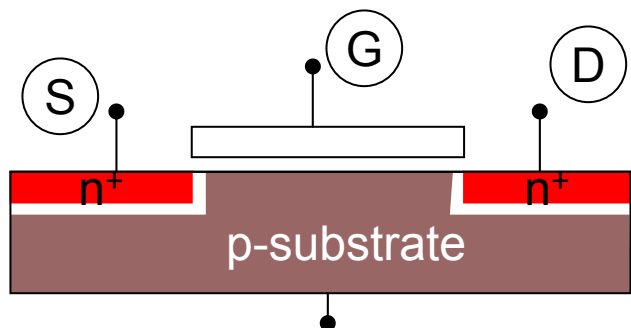


MOSFET transistors have lower power consumption than that of BJT transistors

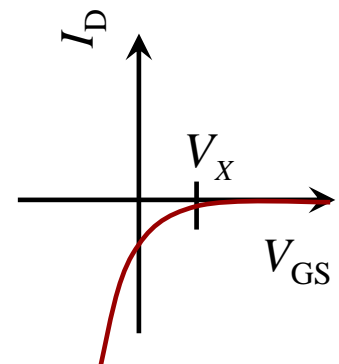
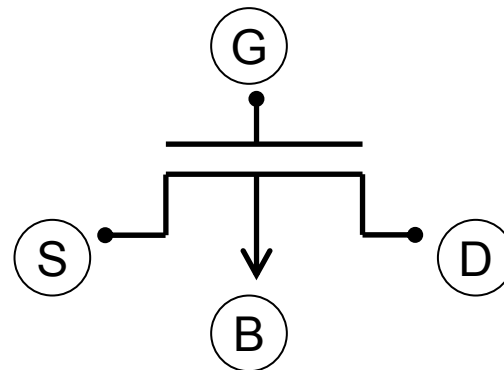
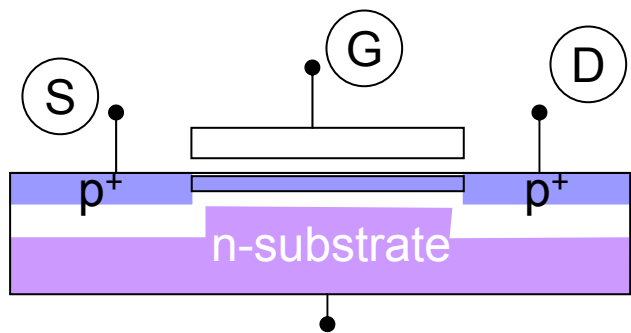
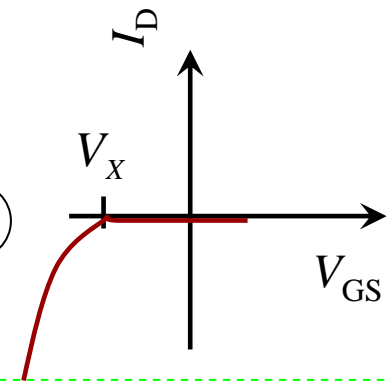
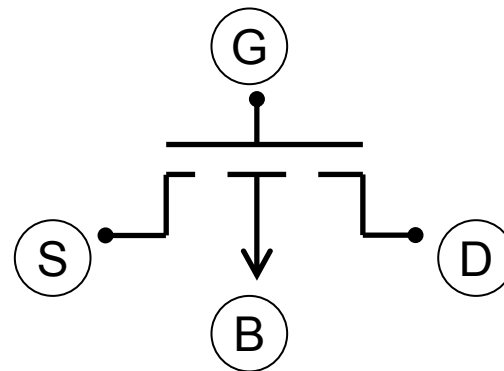
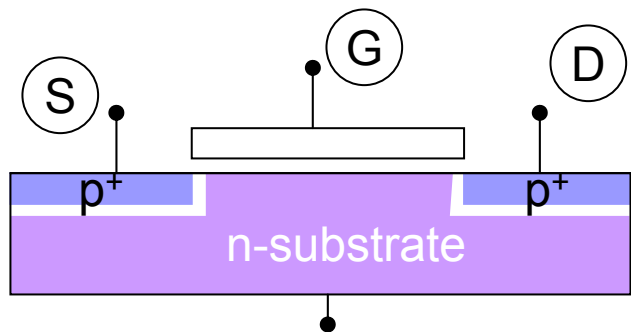


Types of MOSFETs

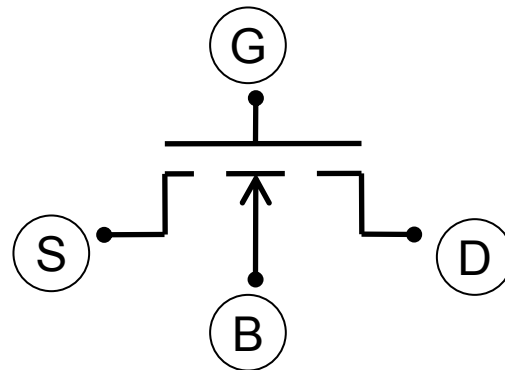
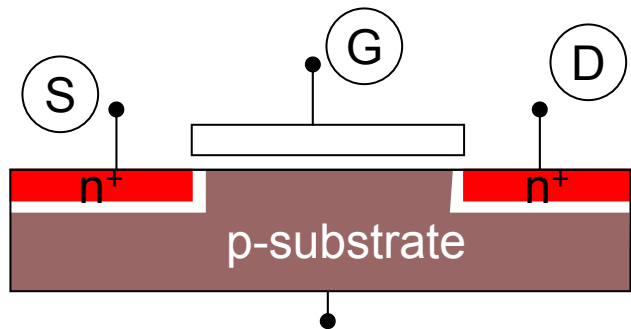
✓ faster (mobility of electrons is higher than of holes)



Types of MOSFETs



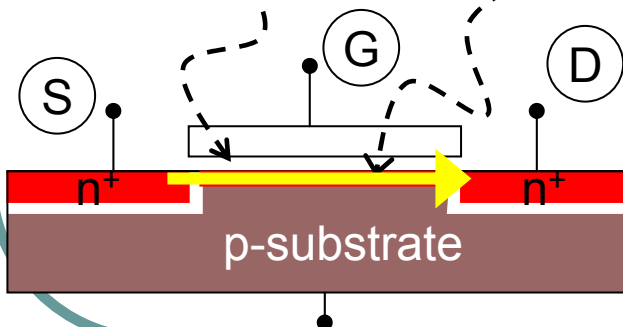
N-MOSFET



The Drain-to-Source current (electrons are emitted from the source to the drain) $I_{DS} > 0$

$$V_{GS} > V_{TN} \quad \& \quad V_D > V_S$$

V_{TN} is the threshold voltage and defined as the **minimum** V_{GS} needed to create a channel between the source and the drain



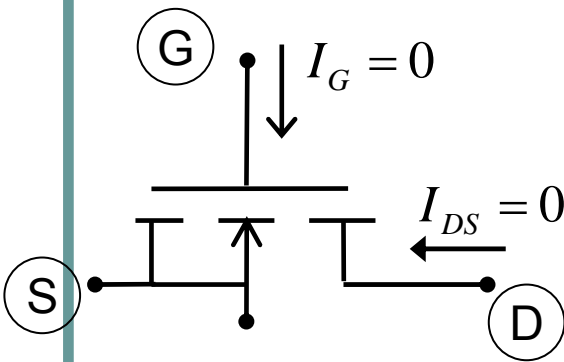
N-MOSFET (Modes of Operation)

There are three modes of operation of N-channel MOSFET (assuming the substrate and the source are connected)

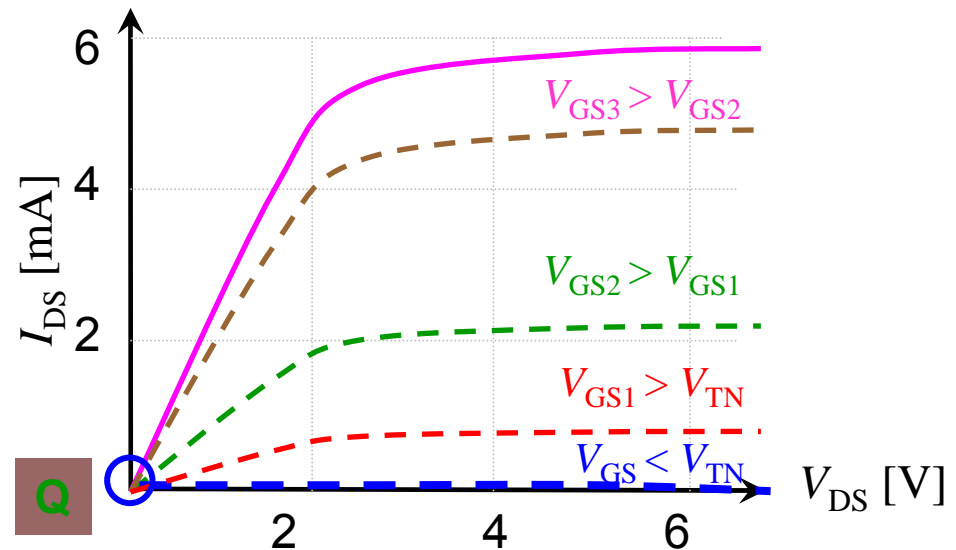
Cut-Off

① Mode

$$(V_{GS} < V_{TN})$$



$$I_{DS} = 0$$



N-MOSFET (Modes of Operation)

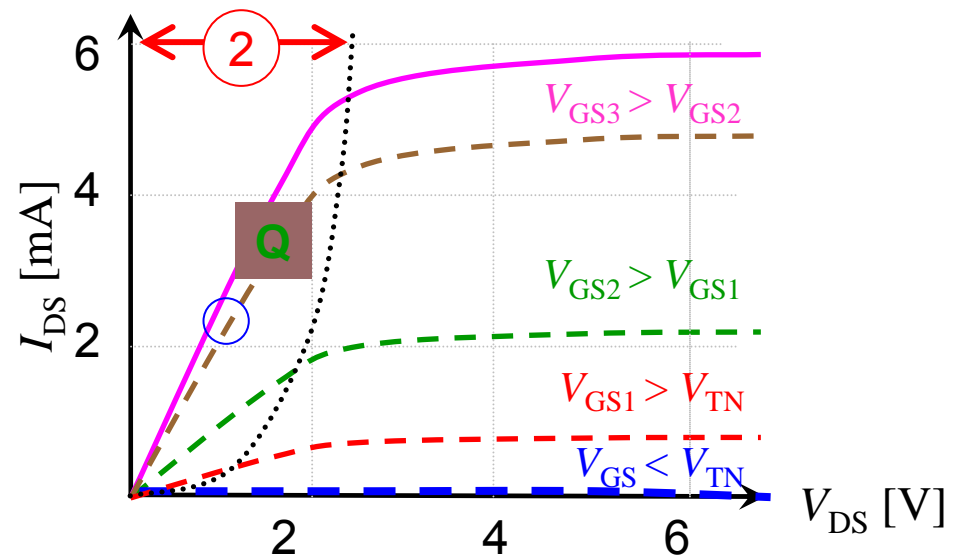
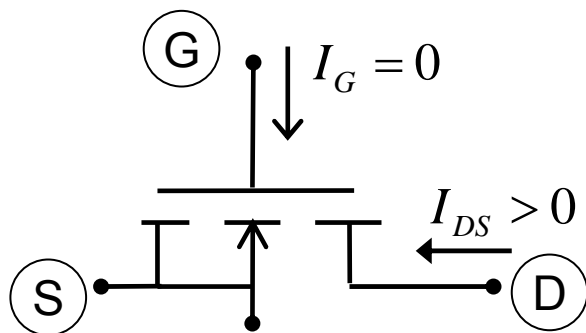
There are three modes of operation of N-channel MOSFET (assuming the substrate and the source are connected)

Linear

② Mode

$$(V_{GS} \geq V_{TN})$$

$$V_{DS} \leq V_{GS} - V_{TN}$$



$$I_{DS} = \frac{K_n}{2} [2 \times (V_{GS} - V_{TN}) V_{DS} - V_{DS}^2]$$

N-MOSFET (Modes of Operation)

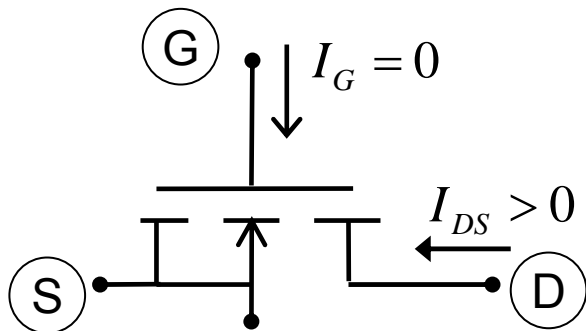
There are three modes of operation of N-channel MOSFET (assuming the substrate and the source are connected)

Saturation

3 Mode

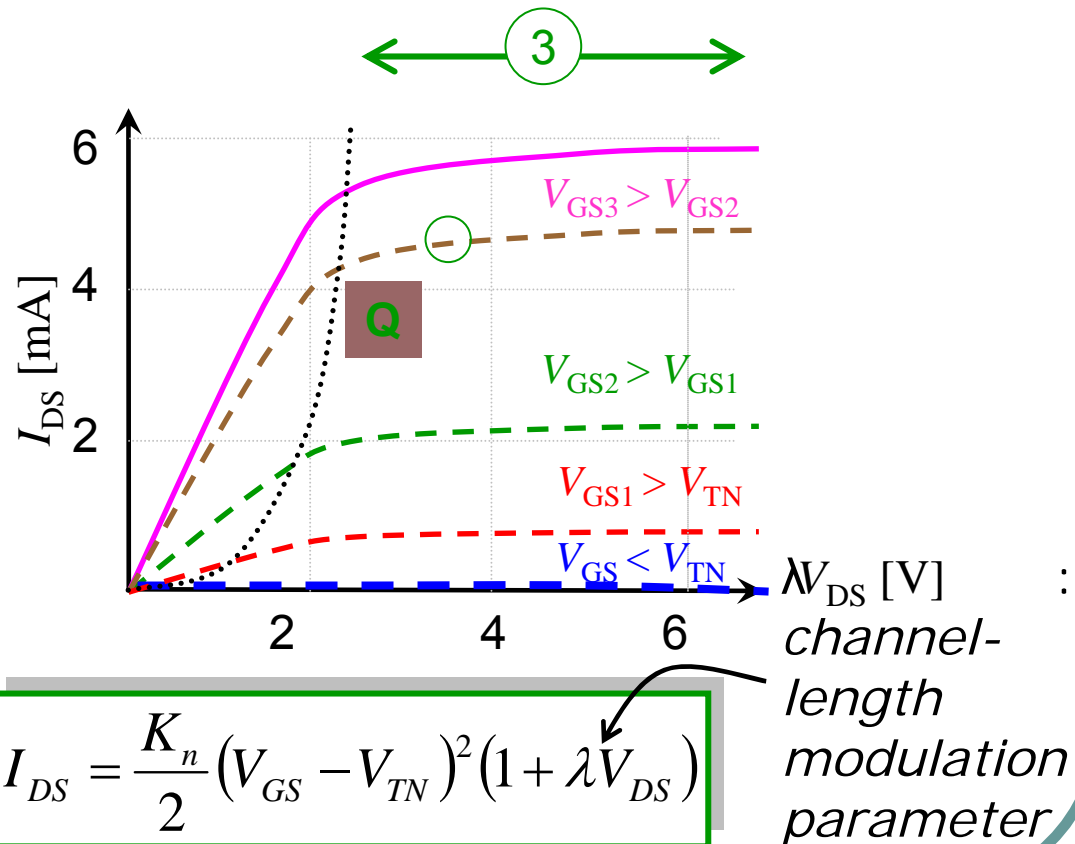
$$(V_{GS} \geq V_{TN})$$

$$V_{DS} \geq V_{GS} - V_{TN}$$



$$I_{DS} = \frac{K_n}{2} (V_{GS} - V_{TN})^2$$

$$I_{DS} = \frac{K_n}{2} (V_{GS} - V_{TN})^2 (1 + \lambda V_{DS})$$



λV_{DS} [V] :
channel-length
modulation
parameter

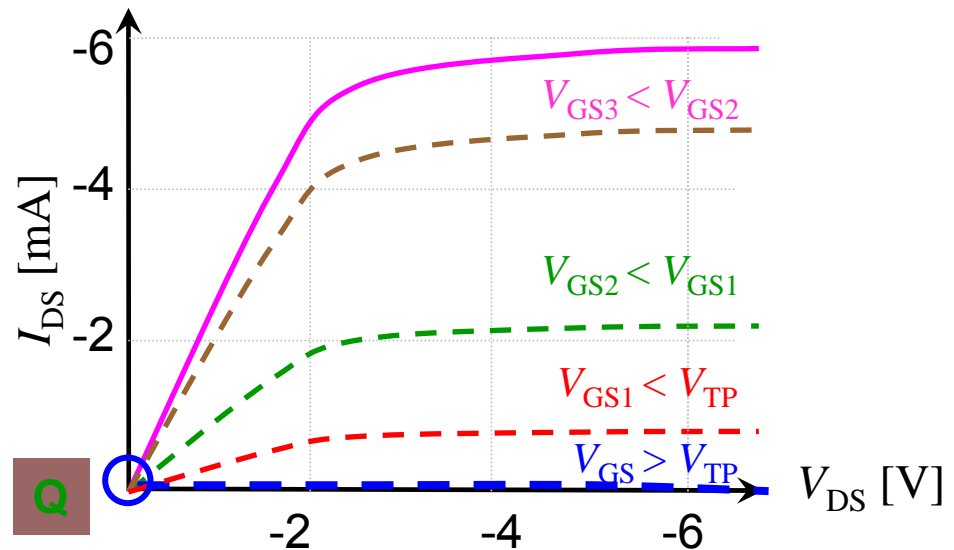
N-MOSFET (Modes of Operation)

There are three modes of operation of P-channel MOSFET (assuming the substrate and the source are connected)

Cut-Off

① Mode

$$(V_{GS} > V_{TP}) \quad V_{TP}^{(-)}$$



$$I_{SD} = 0$$

P- MOSFET (Modes of Operation)

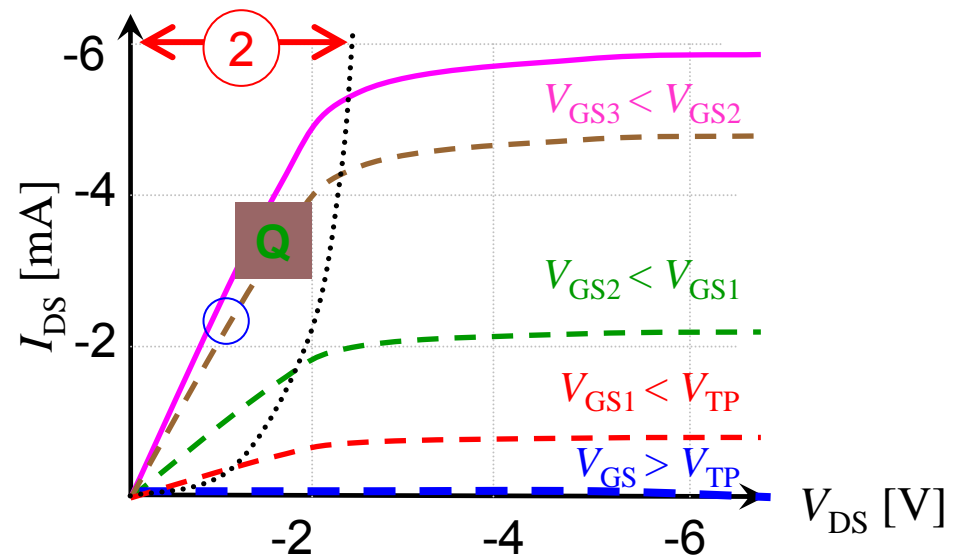
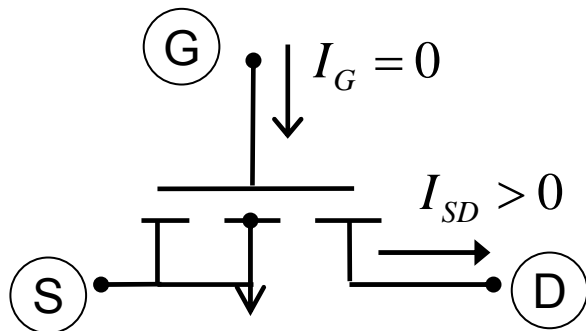
There are three modes of operation of P-channel MOSFET (assuming the substrate and the source are connected)

Linear

② Mode

$$(V_{GS} \leq V_{TP})$$

$$V_{DS} \geq V_{GS} - V_{TP}$$



$$I_{SD} = \frac{K_p}{2} [2 \times (V_{GS} - V_{TP}) V_{DS} - V_{DS}^2] \text{ OR}$$

$$I_{SD} = \frac{K_p}{2} [2 \times (V_{SG} + V_{TP}) V_{SD} - V_{SD}^2]$$

P- MOSFET (Modes of Operation)

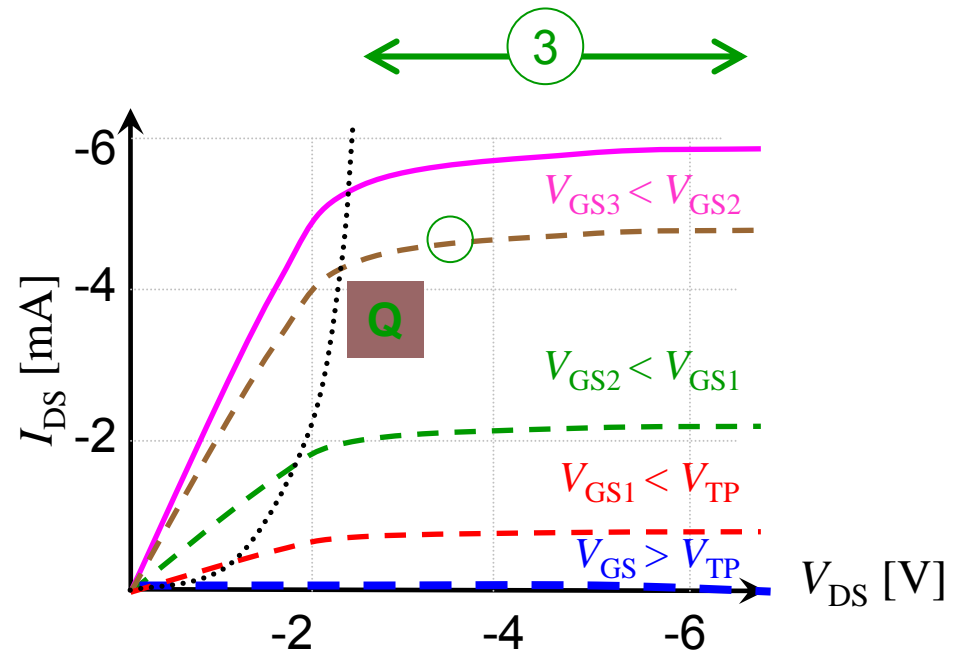
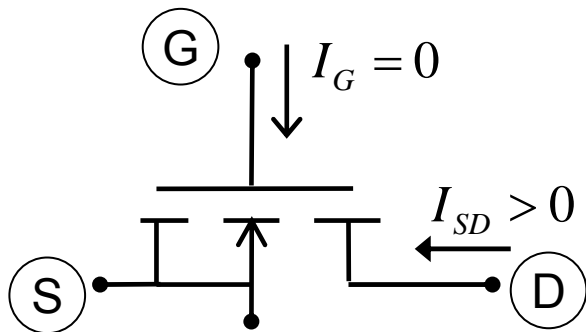
There are three modes of operation of P-channel MOSFET (assuming the substrate and the source are connected)

Saturation

3 Mode

$$(V_{GS} < V_{TP})$$

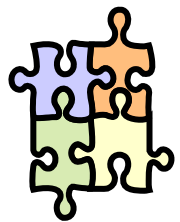
$$V_{DS} \leq V_{GS} - V_{TP}$$



$$I_{SD} = \frac{K_P}{2} (V_{GS} - V_{TP})^2$$

OR

$$I_{SD} = \frac{K_P}{2} (V_{SG} + V_{TP})^2$$



● Example

Determine the drain current of an NMOS transistor assuming $K_n = 20\mu\text{A}/\text{V}^2$, $V_{TN} = 1\text{V}$, $\lambda = 0$, and $V_{GS} = 3\text{V}$

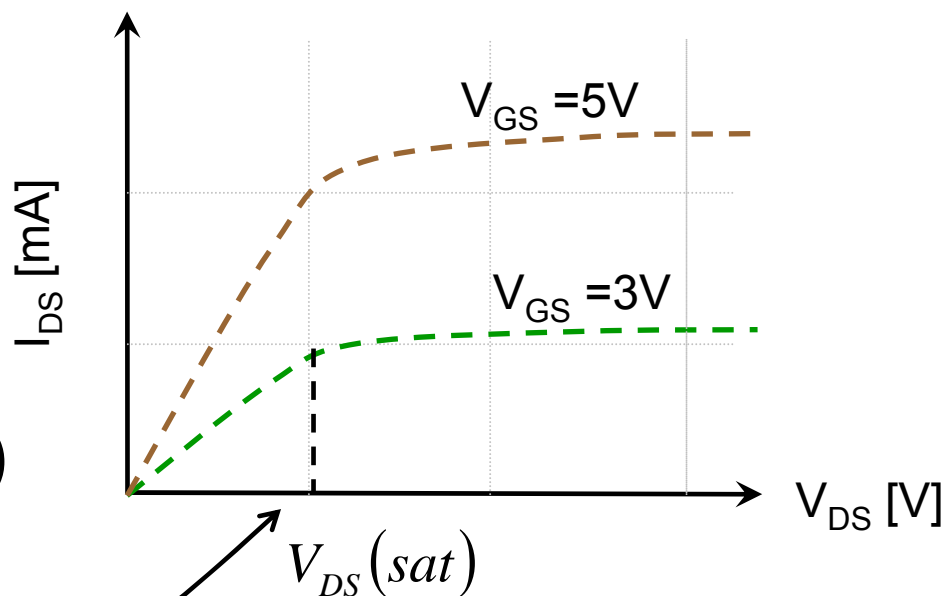
● Solution

$$I_{DS}(sat) = \frac{K_n}{2} (V_{GS} - V_{TN})^2 (1 + \lambda V_{DS})$$

$$I_{DS}(sat) = \frac{20 \times 10^{-6}}{2} (3 - 1)^2 (1 + 0 \times V_{DS})$$

$$I_{DS}(sat) = 40\mu\text{A}$$

$$V_{DS}(sat) = V_{GS} - V_{TN} = 2\text{V}$$



Skip the MOSFET capacitances (sec. 6.7) and the fabrication processes of MOSFET devices